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Electron-Hole Scattering and the Electrical Resistivity of the Semimetal TiS₂ †

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We present the first complete theory of the effect of collisions between charge carriers on the electrical resistivity of a simple degenerate semimetal. We find that (i) electronhole scattering can explain the anomalous T^2 resistivity of *stoichiometric* TiS₂, (ii) electron-electron and hole-hole scattering do not contribute to ρ , and (iii) the theory of electron-hole scattering predicts that the resistivity of *nonstoichiometric* TiS₂ should fall significantly below T^2 at high temperatures.

In a recent Letter Thompson¹ reported that the a-axis, temperature-dependent electrical resistivity, $\rho(T) - \rho(0)$, of the layered semimetallic compound TiS_2 was proportional to T^2 from at least 10 to 400 K. Thompson suggested that this remarkable behavior was due to "general" electron-electron scattering which encompasses electron-electron (e-e), hole-hole (h-h), and electron-hole (e-h) processes. In this Letter we present the first complete theory of the effect of collisions between charge carriers on the electrical resistivity of a simple degenerate semimetal. In TiS₂ the electron and hole densities are sufficiently small and the carrier pockets (assumed spherical) are sufficiently isolated that all e-e, h-h, and e-h scatterings conserve momentum. Therefore e-e and h-h processes do not contribute to ρ . For e-h scattering momentum conservation does not imply current conservation; and we find that this mechanism can explain the observed T^2 resistivity. Furthermore, the theory of e-h scattering suggests additional experiments to confirm the validity of this explanation.

Specifically our theory predicts that a compensated (stoichiometric) semimetal has a T^2 term in the resistivity [Eq. (8)] for all *T*, as has been found in TiS₂. An extension of the theory predicts that the resistivity of an uncompensated (nonstoichiometric) semimetal, e.g., Ti_{1+x}S₂, should fall significantly below T^2 at high *T*, eventually going linearly with temperature as a result of phonon scattering. The particular behavior we predict for Ti_{1+x}S₂ is shown in Fig. 1, where we plot the temperature-dependent resistivity versus T^2 for different values of *x*. For *stoichiometric* TiS₂, *x* = 0, the solid curve including e-h and impurity scattering is pure T^2 and the dashed curve including some phonon scattering shows only a slight deviation. Both are consistent with the data of Thompson. For *nonstoichiometric* TiS_2 our predictions are quite different. At low T, ρ is also proportional to T^2 , but with a coefficient that decreases with x. At higher T, however, the curves fall far below T^2 . The solid curves become constant at high T, while the dashed curve



FIG. 1. Theoretical temperature-dependent electrical resistivity of $Ti_{1+x}S_2$ for different values of x. The solid curves include electron-hole and impurity scattering. The dashed curves illustrate the changes that occur when phonon scattering is included.

becomes linear in T due to phonon scattering. The fact that e-h scattering is required to explain the unusual stoichiometric data is itself surprising, but our off-stoichiometry predictions are an extraordinary and, we believe, unique signature of e-h scattering. Consequently the results of experiments on nonstoichiometric samples will provide a crucial test of our theory, which, if confirmed, would yield additional strong evidence for the existence of holes in TiS₂.

Our results for the resistivity are derived from exact solutions of the coupled electron-hole Boltzmann equations, found using the method of $H\phi j$ gaard-Jensen, Smith, and Wilkins.² Because the inclusion of impurity and phonon-scattering complicates the theory, exact results are not generally available; but an accurate (10%) approximate solution is obtained. Rather than reporting the details of that calculation, we choose to emphasize the physics of electron-hole scattering by writing simple, coupled, electron and hole kinetic equations in the relaxation-time approximation that, with a proper choice of parameters, reproduce exactly our more complicated analysis.

Baber³ first showed that e-h scattering leads to a T^2 resistivity in transition metals. Appel⁴ presented, without derivation, an expression for the total conductivity of an e-h system, which though similar to ours, leads to the erroneous conclusion that the resistivity of a compensated system no longer has a T^2 term at high temperature.

Our theory strictly applies to any degenerate e-h system with spherical carrier pockets in which collisions between charge carriers conserve momentum; although we consider only TiS_2 , many of the features are quite general and should be of interest to those concerned with transport in elemental semimetals, transition metals, and the new "unusual" metals such as the layered compounds, $(SN)_x$ and tetrathiafulvalene tetracyanoquinodimethane (TTF-TCNQ).⁵

TiS₂ has a hexagonal Brillouin zone. Although existing band structure calculations⁶ predict that it is a semiconductor, experiments¹ indicate that it is a semimetal. Following the recent suggestion of Freeman and Zunger,⁷ we assume a pocket of holes at Γ and electron pockets at the *M* points. This structure is shown in Fig. 2. TiS₂ is a layered compound, but with a small anisotropy ratio, $\rho_c/\rho_a < 10$. Since detailed Fermi surface data are not available, we assume the simple case of spherical carrier pockets.⁵ For stoichiometric TiS₂, the density of electrons and holes are equal so that $n_e = n_h = n_0 = 2 \times 10^{20}$ cm⁻³.⁸



FIG. 2. Reciprocal lattice of TiS_2 viewed along the c axis. The large circles denote pockets of holes and the small circles pockets of electrons. The three different types of electron-hole scattering are indicated.

To illustrate the importance of momentum conservation, we consider first e-e scattering. The current carried by the electrons is given by

$$\vec{\mathbf{J}}_e = (-e/m_e) \sum n_i \vec{\mathbf{p}}_i \equiv (-e/\Omega m_e) \vec{\mathbf{P}}_e , \qquad (1)$$

where $\vec{p}_i = m_e \vec{v}_i$ is the physical momentum of an electron in state i, n_i is the distribution function, and Ω is the volume of the sample. The current is proportional to the total momentum $\mathbf{\tilde{P}}_{s}$ in the electron system. The wave vector of the *i*th electron is $\vec{q}_i = \vec{K}_i + \vec{p}_i$ where \vec{K}_i is the vector from the origin to the center of the pocket containing the ith electron. In an e-e collision, wave vector is conserved which implies that $\vec{q}_1 + \vec{q}_2 = \vec{q}_3 + \vec{q}_4 + \vec{G}$, where G is a reciprocal lattice vector (including \vec{G} = 0). In terms of momenta, this reads $\vec{p}_1 + \vec{p}_2$ $= \vec{p}_3 + \vec{p}_4 + \vec{Q}$, where $\vec{Q} = \vec{K}_3 + \vec{K}_4 - \vec{K}_1 - \vec{K}_2 + \vec{G}$. A process in which $\mathbf{Q} = 0$ conserves momentum and therefore cannot affect the current. In TiS₂ the smallest nonzero $|\mathbf{Q}| = 1.1 \, \mathrm{\AA^{-1}}$ is greater than the maximum momentum transfer $4p_{\rm F} = 0.50 \text{ Å}^{-1}$; therefore, momentum nonconserving e-e processes do not occur at all. We conclude that e-e scattering does not contribute to the electrical resistivity of TiS₂.⁹ The same conclusion applies to h-h scattering.

We now turn our attention to e-h scattering. The current carried by the e-h system is simply written in terms of the total electron and hole momenta as

$$\mathbf{\tilde{J}} = (-e/\Omega)(\mathbf{\tilde{P}}_e/m_e - \mathbf{\tilde{P}}_h/m_h).$$
⁽²⁾

It is more physical to rewrite this expression in

terms of the total and relative momenta defined by

$$\vec{\mathbf{P}} = \vec{\mathbf{P}}_e + \vec{\mathbf{P}}_n,$$

$$\vec{\mathbf{C}} = \mu (\vec{\mathbf{P}}_e / n_e m_e - \vec{\mathbf{P}}_h / n_h m_h) = \Omega \mu (\vec{\mathbf{V}}_e - \vec{\mathbf{V}}_h),$$
(3)

where $1/\mu = 1/n_e m_e + 1/n_h m_h$ and $\vec{V}_e - \vec{V}_h$ is the relative velocity of the electrons and holes. Thus the current becomes

$$\vec{\mathbf{J}} = \frac{-e}{\Omega} \left[\left(\frac{n_e - n_h}{n_e m_e + n_h m_h} \right) \vec{\mathbf{P}} + \left(\frac{1}{m_e} + \frac{1}{m_h} \right) \vec{\mathcal{C}} \right].$$
(4)

In general \vec{J} depends on both the total and relative momenta. Using the same reasoning as for e-e scattering, we see that e-h scattering also conserves the total momentum in TiS₂. However, the the relative momentum is degraded by e-h scattering. For a stoichiometric sample, \vec{J} is independent of \vec{P} and there is a finite conductivity due to e-h scattering alone. In contrast a nonstoichiometric system with only e-h scattering has an infinite conductivity; impurities and phonons must be introduced to relax the total momentum. This fundamental difference between a compensated and uncompensated system leads to surprising consequences.

Consider an electron-hole system in an external field $\vec{\mathbf{E}}$ with e-h, impurity, and phonon scattering. In the steady state the total rate of the change $\vec{\mathbf{P}}_e$ is zero, i.e., $d\vec{\mathbf{P}}_e/dt|_{\text{total}} = d\vec{\mathbf{P}}_e/dt|_{\vec{\mathbf{E}}} + d\vec{\mathbf{P}}_e/dt|_{\text{eh}} + d\vec{\mathbf{P}}_e/dt|_{\text{ip}} = 0$, where the change due to $\vec{\mathbf{E}}$ is $d\vec{\mathbf{P}}_e/dt|_{\vec{\mathbf{E}}} = -n_e\Omega\vec{\mathbf{E}}$. Impurities and phonons relax $\vec{\mathbf{P}}_e$ toward zero; $d\vec{\mathbf{P}}_e/dt|_{\text{ip}} = -\vec{\mathbf{P}}_e/\tau_{\text{ip}}$, where $1/\tau_{\text{ip}} = 1/\tau_{\text{imp}} + 1/\tau_{\text{phon}}$. A new feature of this calculation is the recognition that electron-hole scattering relaxes the *relative* velocity or *relative* momentum to zero;

$$\left. d\vec{\Phi}/dt \right|_{\rm eh} = -\vec{\Phi}/\tau_{\rm eh} = d\vec{\mathbf{P}}_e/dt \big|_{\rm eh} = -d\vec{\mathbf{P}}_h/dt \big|_{\rm eh}.$$
(5)

Making the same analysis for the total hole momentum and writing \vec{P}_e and \vec{P}_h in terms of \vec{P} and $\vec{\Phi}$, we find the coupled kinetic equations

$$0 = -en_e \Omega \dot{\mathbf{E}} - \dot{\mathcal{O}} / \tau_{eh} - [\dot{\mathcal{O}} + (\mu/n_h m_h) \mathbf{P}] / \tau_{ip},$$

$$0 = en_h \Omega \vec{\mathbf{E}} + \vec{\mathcal{O}} / \tau_{eh} - [-\vec{\mathcal{O}} + (\mu/n_e m_e) \vec{\mathbf{P}}] / \tau_{ip},$$
(6)

where we have assumed that τ_{ip} was the same for electrons and holes. Solving we obtain the following expression for the conductivity:

$$\sigma = e^{2} \mu \left[\frac{(n_{e} - n_{h})^{2}}{n_{e} n_{h} m_{e} m_{h}} \tau_{ip} + \left(\frac{1}{m_{e}} + \frac{1}{m_{h}} \right)^{2} \left(\frac{1}{1/\tau_{eh} + 1/\tau_{ip}} \right) \right] , \qquad (7)$$

where the first term derives from $\overline{\mathbf{P}}$ and second

from $\vec{\Phi}$. The relaxation rates obtained from our Boltzmann equation analysis are given in Eqs. (9) and (10). We note that $1/\tau_{inup}$ is a constant independent of temperature; $1/\tau_{phon}$ is given by a Bloch-Grüneisen function, thus varying as T^5 for low T and linearly at high T; $1/\tau_{eh}$ is proportional to T^2 at all temperatures.

On stoichiometry, the term deriving from $\mathbf{\tilde{P}}$ disappears and the resistivity reduces to

$$\rho = \frac{1}{\sigma} = \frac{1}{ne^2} \left(\frac{1/\tau_{\rm eh} + 1/\tau_{\rm ip}}{1/m_e + 1/m_h} \right). \tag{8}$$

At low temperatures, phonons may be ignored and $\rho = A + CT^2$. At high *T*, phonons contribute a linear term and $\rho = A + BT + CT^2$. For sufficiently small *B/C*, the *T*² term dominates for all *T* as observed in TiS₂. For other materials with a large *B/C*, ρ will look phononlike at intermediate temperatures. We note, however, that the *T*² term is present for all *T* and eventually dominates.

Off stoichiometry, the first term in Eq. (7) no longer vanishes and this dramatically changes the high-temperature limit where the second term becomes negligible compared with the first and $\rho = A' + B'T$, which has no T^2 term at all. This surprising result may be understood by recalling that e-h scattering, which predominates at very high T, tends to make the relative velocity equal to zero. When this occurs, both electrons and holes are carried at the drift velocity; and the current, proportional to the net charge $-e(n_e - n_h)$, is degraded only by impurity and phonon scattering.

Our theory completely specifies the resistivity in terms of the electron-hole interaction, the electron-phonon coupling constant λ , and $1/\tau_{imp}$. Unfortunately the interaction between *d* electrons and *p* holes is not known and therefore we simply assume a constant (in *q*) e-h scattering rate *W* which we take to be the same for all three types of e-h scattering shown in Fig. 1. This yields

$$\frac{1}{\tau_{\rm eh}} = \frac{n_h m_e}{\mu} \frac{(k_{\rm B}T)^2 W}{\pi^2 \hbar^6} \times \left(\frac{m_e m_h^2 \alpha^3}{3} + \frac{m_e^2 m_h (3\alpha - 1)}{4} \right), \qquad (9)$$

where $\alpha = 1$ (p_F/k_F) for p_F/k_F greater (less) than 1; k_F is the Fermi wave vector for holes. A crude estimate of *W* is given by $W \approx (2\pi/\hbar) V_{TF}^2$, where V_{TF} is the q = 0 Thomas-Fermi interaction, known to be too weak for electron-electron scattering in the alkali metals.¹⁰

For stoichiometric TiS_2 , this yields a resistiv-

ity too small by a factor of 16; and we must choose the interaction four times stronger than $V_{\rm TF}$ to fit the observed T^2 term.

For $1/ au_{
m phon}$ we use

$$1/\tau_{\rm phon} = (2\pi/\hbar)\lambda k_{\rm B}T [4(T/\theta_{\rm R})^4 J_5(\theta_{\rm R}/T)], \qquad (10)$$

where $\theta_R = 2p_F v_{sound}$ and J_5 is a Debye integral. Since our theory predicts that $\rho = A + BT + CT^2$ for stoichiometric TiS₂ at high *T* and the linear term is not evident experimentally, we conclude that the electron-phonon coupling constant is rather small ($\lambda \leq 0.05$), which we do not fully understand. $1/\tau_{imp}$ is now determined by the observed resistivity ratio of 10. [Our e-h analysis of experiment⁸ shows that $1/\tau_{ip}$ is not the same for electrons and holes as assumed in Eq. (6) and that a straightforward generalization is required.]

Nonstoichiometric TiS_2 is obtained by intercalating additional Ti atoms, which are each assumed to give up four electrons. Calculating the electron and hole densities as functions of x in $\text{Ti}_{1+x} \text{S}_2$, we find that all the holes are filled when $n_e = 5.4n_0$ or x = 0.015. Using the same parameters as for stoichiometric TiS_2 and assuming further that $1/\tau_{ip}$ scales as the density of states, we are able to calculate the temperature-dependent resistivity of $\text{Ti}_{1+x} \text{S}_2$ for different values of x. We exhibit curves for $\lambda_e = \lambda_h = 0$ and 0.05 in Fig. 1, which has been discussed earlier.

In conclusion, we emphasize that the general features of our off-stoichiometry predictions are independent of our crude approximation to the e-h interaction; and, therefore, these experiments will provide a severe test of the theory. Obvious-

ly more work on the interaction is needed, but the additional effort will be justified only if experiments confirm that e-h scattering is the dominant mechanism. Thompson informs us that systematic measurements on nonstoichiometric samples are now underway and his preliminary results are in qualitative agreement with our predictions.

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 τ_{ip}^{noise} = 3.4 at 300 K. A nonspherical Fermi surface can allow a nonzero contribution due to e-e scattering.

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COMMENTS

Charm Spectroscopy via Electron-Positron Annihilation*

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Electron-positron annihilation should be a rich source of charmed hadrons. The search for invariant-mass peaks together with the measurement of recoil-mass spectra is a technique that recently has borne fruit at SPEAR. We show how this technique may reveal the existence of the charmed baryons and of the excited states of the charmed mesons.

Charmed hadrons should be abundant in debris of e^-e^+ annihilation above the charm threshold.¹ A good candidate for the lightest charmed particle D^0 was found at SPEAR² at 1.865 GeV decaying into $K^-\pi^+$ and $K^-\pi^-\pi^+\pi^+$, presumably a $J^P = 0^-$ S-wave $c\bar{u}$ meson. Its isotopic partner D^+ must